

10/17, 683

07/03

JACOBSON HOLMAN, PLLC  
 400 SEVENTH STREET, N.W.  
 WASHINGTON, D.C. 20004-2201

## LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

2829

ATTY. DOCKET NO.: P68985US0  
 SERIAL NO.: New Application  
 APPLICANT(S): Sang-Don LEE

GROUP ART UNIT: Not Yet Assigned  
 FILING DATE: July 14, 2003  
 TODAY'S DATE: July 14, 2003

\*\*\*\*\*

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	INT'L CLASS	SUB- CLASS	FILING DATE (If Appropriate)
AA						
AB						

\*\*\*\*\*

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	SUB- CLASS	TRANSLATION (YES) (NO)
AC					
AD					
AE					

\*\*\*\*\*

## OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

LF AF : Udo SCHWALKE, et al.; "Dual-Workfunction Gate Engineering in a Corner Parasitics-Free Shallow-Trench-Isolation Complementary-Metal-Oxide-Semiconductor Technology"; Jpn. J. Appl. Phys. Vol. 38; 1999; pp.2232-2237.

AG

EXAMINER Marlina DATE CONSIDERED 9/17/04

\* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).